

AN 2002-323696 [36] WPIDS
 DNC C2002-094211 [36]
 DNN N2002-254023 [36]
 TI Electrode wire for wire electrical discharge processings, comprises
 specific amount of tin and indium, remainder of copper and unavoidable
 impurity
 DC M11; M23; M26; P54
 IN KIMURA T; KURODA H; MATSUZAKI H; NAGAI T; SATO T; SAWAHATA K
 PA (HITD-C) HITACHI CABLE LTD
 CYC 1
 PIA JP 2002047520 A 20020215 (200236)* JA 6[0] <--
 JP 3941352 B2 20070704 (200744) JA 9
 ADT JP 2002047520 A JP 2000-233175 20000728; JP 3941352 B2 JP
 2000-233175 20000728
 FDT JP 3941352 B2 Previous Publ JP 2002047520 A
 PRAI JP 2000-233175 20000728
 AB JP 2002047520 A UPAB: 20050525
 NOVELTY - The electrode wire comprises 0.01-2.40 weight% of each of
 indium and tin, and remainder of copper and unavoidable impurity.
 DETAILED DESCRIPTION - An INDEPENDENT CLAIM is also included for
 the electrode wire manufacturing method.
 USE - For wire electrical discharge processings of hard cutting
 materials such as graphite and sintered metal.
 ADVANTAGE - The electrode wire of desired diameter has excellent
 electrical discharge processing characteristics and favorable wire drawing
 property.